

# Room temperature energy-efficient spin-orbit torque switching in two-dimensional van der Waals $\text{Fe}_3\text{GeTe}_2$ induced by topological insulators

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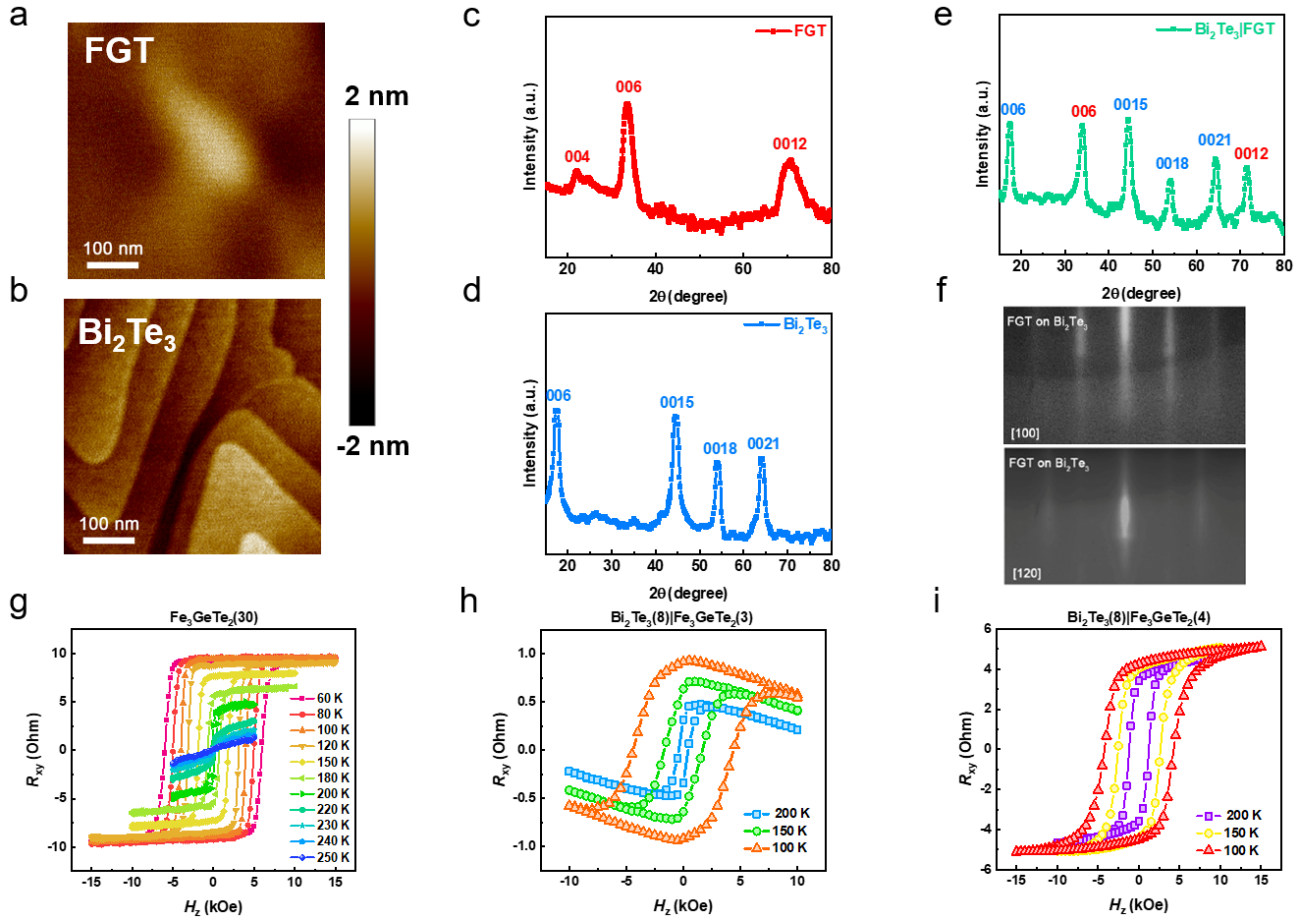
## Supplementary information

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## 1. Structural characteristics and magnetic property of FGT, Bi<sub>2</sub>Te<sub>3</sub>, and Bi<sub>2</sub>Te<sub>3</sub>/FGT heterostructures

To understand the microstructure and surface morphology, the structural characteristics of FGT, Bi<sub>2</sub>Te<sub>3</sub>, and Bi<sub>2</sub>Te<sub>3</sub>/FGT heterostructure were measured, and the results are shown in Fig. S1. The atomic force microscopy (AFM) results corresponding to FGT and Bi<sub>2</sub>Te<sub>3</sub> are shown in Fig. S1a and Fig. S1b, respectively. Bi<sub>2</sub>Te<sub>3</sub> shows a terraced surface that is well consistent with the previously-reported surface morphology of Bi<sub>2</sub>Te<sub>3</sub><sup>1,2</sup>. In contrast, the FGT shows a smoother surface rather than a terrace. The crystal structures were characterized by X-ray diffraction (XRD), and typical results from pure FGT and Bi<sub>2</sub>Te<sub>3</sub> are respectively shown in Fig. S1c and Fig. S1d. According to PDF Card #75-5620 and #15-0863, the XRD peaks can be determined to be a series of {002} planes from FGT and {003} planes from Bi<sub>2</sub>Te<sub>3</sub>, respectively. The XRD scanning result of Bi<sub>2</sub>Te<sub>3</sub>/FGT heterostructure is shown in Fig. S1e, in which the corresponding peaks from FGT and Bi<sub>2</sub>Te<sub>3</sub> are marked separately in red and blue, showing the high-quality single crystallinity of FGT and Bi<sub>2</sub>Te<sub>3</sub> in Bi<sub>2</sub>Te<sub>3</sub>/FGT heterostructure. Typical RHEED results are shown in Fig. S1f, which clearly demonstrates two types of steaky patterns in different crystal orientations, corresponding to [100] and [120] incident beams respectively. Therefore, we confirm that the high-quality crystal was obtained with no in-plane domains. Meanwhile, anomalous Hall measurement was carried out to characterize their magnetic properties, and typical results from FGT and Bi<sub>2</sub>Te<sub>3</sub>/FGT are shown in Fig. S1g-i, which clearly demonstrate the PMA features.

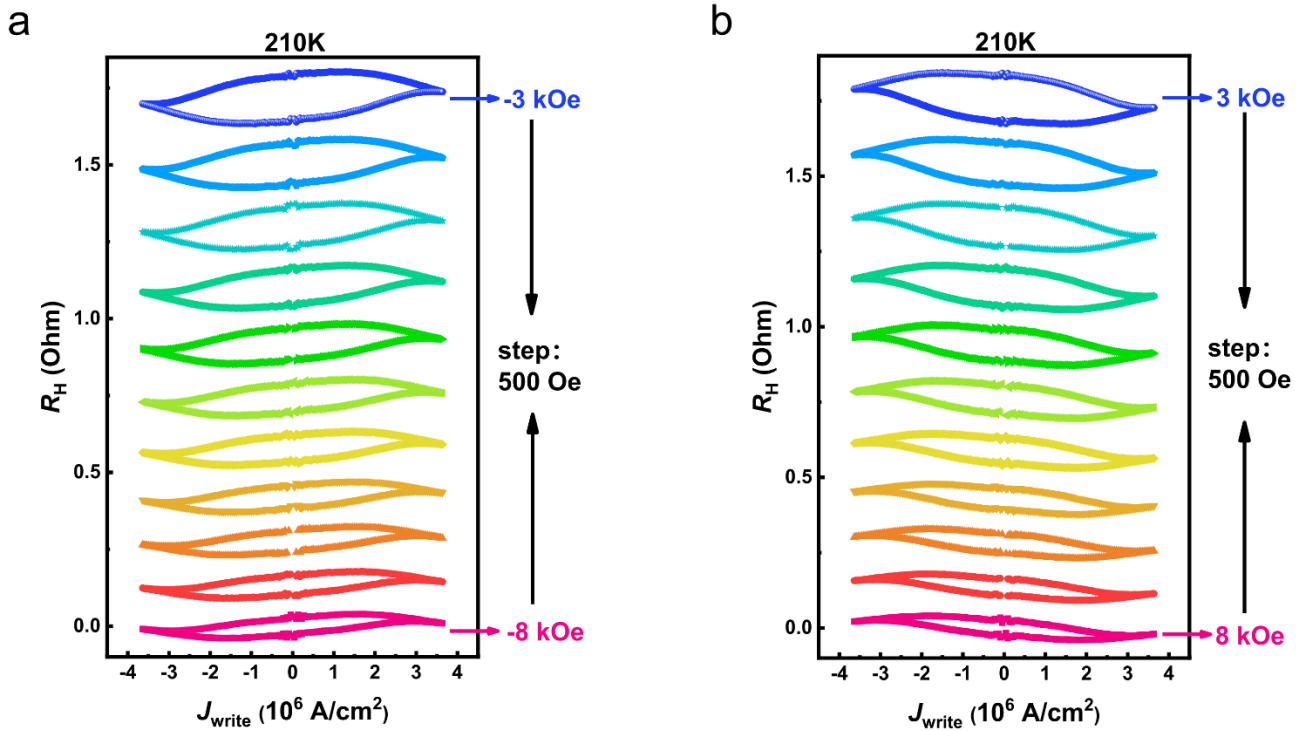


**Figure S1 | Structural characteristics and magnetic property of FGT,  $\text{Bi}_2\text{Te}_3$ , and  $\text{Bi}_2\text{Te}_3/\text{FGT}$  heterostructures.** **a, b** AFM images of FGT and  $\text{Bi}_2\text{Te}_3$ , respectively showing the smooth surface of FGT and terrace surface of  $\text{Bi}_2\text{Te}_3$ . **c-e** XRD measurements of pure FGT, pure  $\text{Bi}_2\text{Te}_3$ , and  $\text{Bi}_2\text{Te}_3/\text{FGT}$  films show the high-quality single crystallinity. **f** RHEED images of  $\text{Bi}_2\text{Te}_3/\text{FGT}$  heterostructure, further showing the high-crystalline quality. **g-i** Anomalous Hall resistance of 30nm FGT,  $\text{Bi}_2\text{Te}_3(8)|\text{FGT}(3)$  and  $\text{Bi}_2\text{Te}_3(8)|\text{FGT}(4)$  at different temperatures, respectively.

## 2. SOT-induced magnetic switching in $\text{Bi}_2\text{Te}_3/\text{FGT}(3)$ heterostructure at 210 K

In addition to the current-induced magnetic switching in the  $\text{Bi}_2\text{Te}_3/\text{FGT}(3)$  heterostructure at 200 K in the main text, we carried out the identical SOT measurement at another temperature of 210 K. Similarly, when applying a constant external in-plane field with sweeping the applied  $J_{\text{write}}$ , the SOT from the charge-spin conversion in  $\text{Bi}_2\text{Te}_3$  can induce the magnetization switching of the FGT layer.

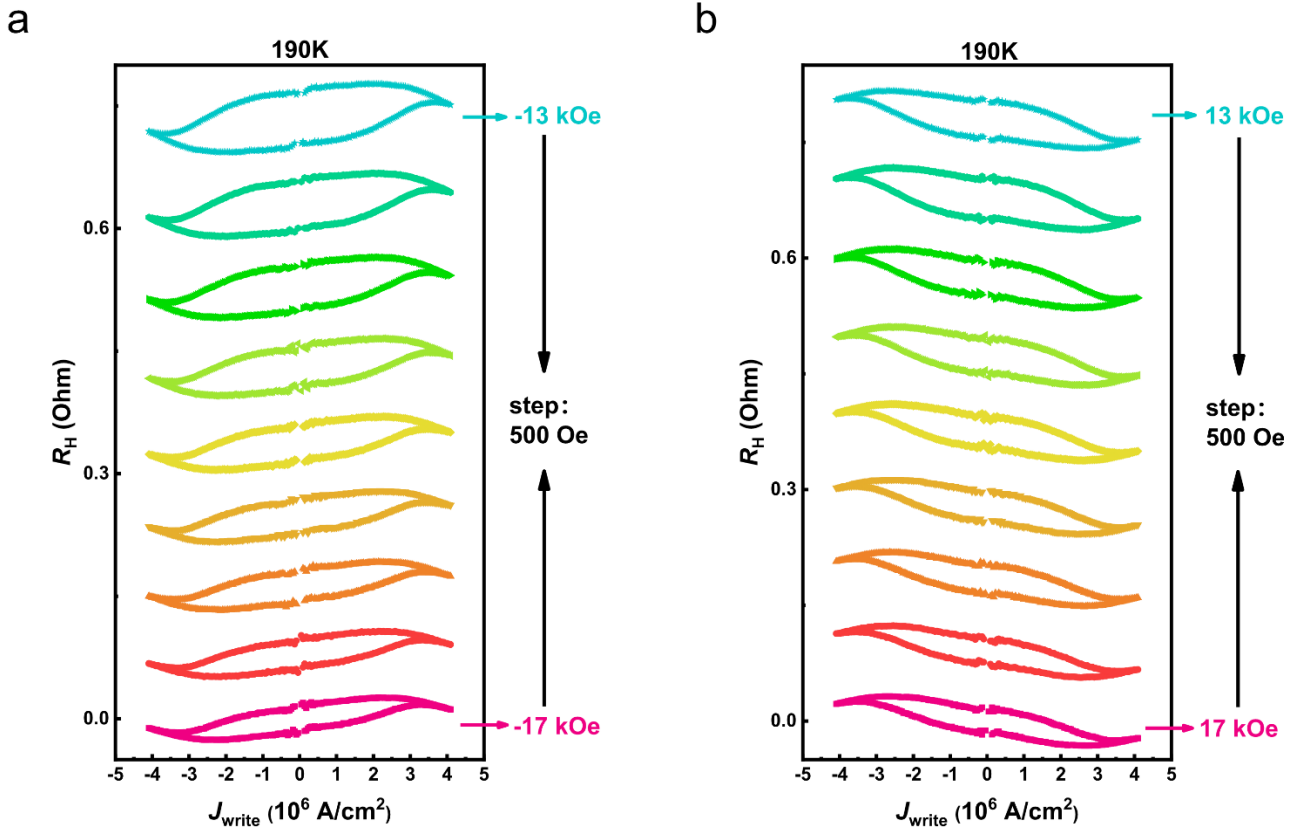
As the external magnetic field increases, the switching current density decreases. When the applied magnetic field is reversed, the SOT switching shows an opposite chirality. All these results well demonstrate the magnetization switching behaviors in the existence of SOT.



**Figure S2 | Spin-orbit torque induced magnetization switching behaviors in  $\text{Bi}_2\text{Te}_3(8)/\text{FGT}(3)$  at 210 K. a, b** SOT-induced magnetization switching behaviors at 210 K under different applied in-plane magnetic field, which show the field-dependent switching chirality and critical switching current density.

### 3. SOT-induced magnetic switching in $\text{Bi}_2\text{Te}_3/\text{FGT}(3)$ heterostructures at 190 K

Utilizing the identical SOT measurement, we performed the current-driven magnetic switching on  $\text{Bi}_2\text{Te}_3(8)/\text{FGT}(3)$  at 190 K, and typical results are shown in Fig. S3. The switching chirality is the same as other temperatures when reversing the external in-plane magnetic field. Based on the above switching behavior, we summarize the temperature-dependent phase diagram of magnetic states in the presence of external magnetic field and current density, as already shown in the main text.

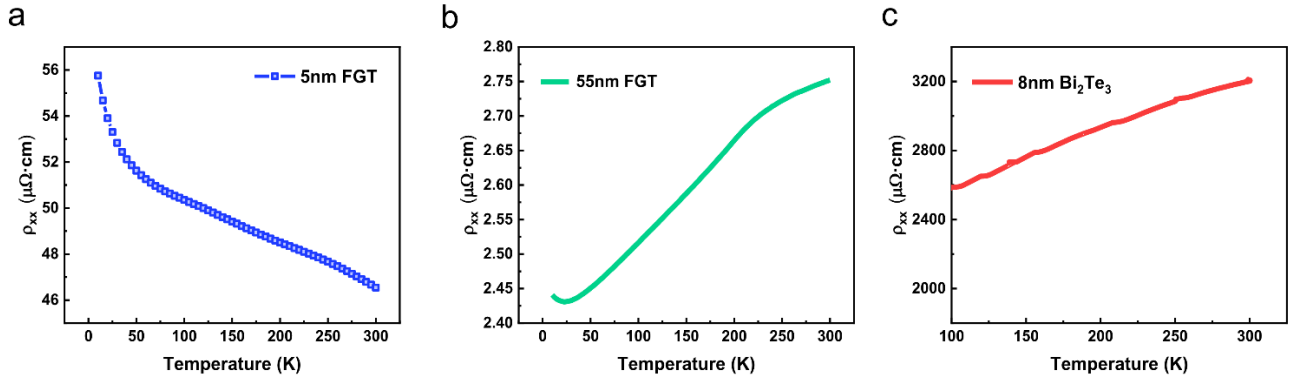


**Figure S3 | Spin-orbit torque induced magnetization switching behaviors in  $\text{Bi}_2\text{Te}_3(8)/\text{Fe}_3\text{GeTe}_2(3)$**

**at 190 K.** a, b SOT-induced magnetization switching behaviors at 190 K, which clearly show the relation between external in-plane field and switching current density for switching.

#### 4. Temperature-dependent resistivity from $\text{Bi}_2\text{Te}_3$ and FGT thin films

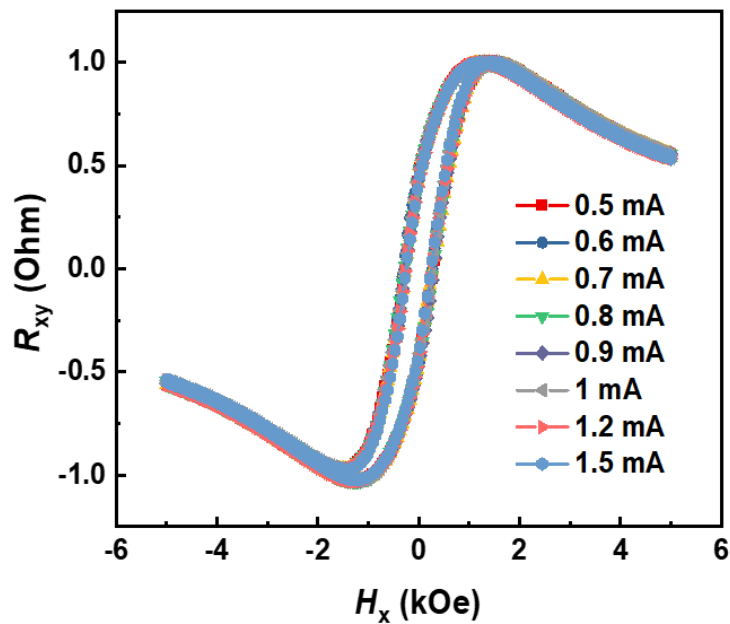
To elucidate the resistivity properties of  $\text{Bi}_2\text{Te}_3$  and FGT, we performed transport measurements by the physical property measurement system. The temperature-dependent resistivity from  $\text{Bi}_2\text{Te}_3$  and FGT is shown in Fig. S4. It shows that the resistivity value of the 5nm-FGT increases with the decrease of temperature, which is due to the surface disorder caused by the thin film sample exposed to the air<sup>3,4</sup>. The R-T curve shows more insulating behaviors, which is in sharp contrast with the metal characteristic of thick FGT in Fig. S4b. It further proves that the thickness dependence will affect the interface of the heterostructure. Fig. S4c displays the typical metallic behavior of 8nm- $\text{Bi}_2\text{Te}_3$  from 100 K to 300 K.



**Figure S4 | Resistivity-temperature curves of  $\text{Bi}_2\text{Te}_3$  and FGT thin films. a, b** Temperature-dependent resistivity of the  $\text{Bi}_2\text{Te}_3$  and FGT device, respectively.

### 5. Magnetotransport properties of $\text{Bi}_2\text{Te}_3/\text{FGT}$ heterostructure

To prove the high interfacial thermal conductance in the  $\text{Bi}_2\text{Te}_3(8)/\text{FGT}(4)$  structure, the sweeping in a large range of in-plane magnetic field was carried out for observing the  $R_{xy}$  changing behavior under different currents, and typical results were shown in Fig. S5. It is found that the loops are almost the same even under large current of 1.5 mA, which prove the high thermal conductance of the  $\text{Bi}_2\text{Te}_3/\text{FGT}$  interface.



**Figure S5 | Transport properties of the  $\text{Bi}_2\text{Te}_3/\text{FGT}$  heterostructures. In-plane field-dependent  $R_{xy}$**

of the Bi<sub>2</sub>Te<sub>3</sub>/FGT device under different currents.

## 6. Harmonic Hall voltage measurement and SOT efficiency calculation in Bi<sub>2</sub>Te<sub>3</sub>(8)/FGT(4)

To accurately describe the damping-like SOT efficiency through a harmonic Hall measurement, two methods are usually employed for fitting the data, including large-field power-law fitting and small field derivation fitting<sup>5,6</sup>. Formula (1) is the extended Landau-Lifshitz-Gilbert (LLG) equation that includes two spin torque terms. Here, the  $\hat{m}$  is a unit vector of the magnetization direction,  $\hat{p}$  is the average spin direction of the electrons diffusing into the magnetic layer,  $\alpha$  is the Gilbert damping constant,  $\gamma$  is the gyromagnetic ration,  $-\frac{\partial E}{\partial \vec{M}}$  is the current independent effective magnetic fields,  $a_J$  is the damping-like (Slonczweski-Berger) term and  $b_J$  is the field-like term<sup>5</sup>. To avoid the thermal-related phenomena from anomalous Nernst effect<sup>7,8</sup>, we perform the fitting on the Bi<sub>2</sub>Te<sub>3</sub>(8)/FGT(3) sample using the former case following formula (2), where the equilibrium direction of the magnetization vector is pointing almost into the in-plane direction. Further, the low field values of  $V_{2\omega}$  provide information of  $b_J$ , whereas the higher-field values give  $a_J$  for in-plane magnetic anisotropy (IMA). Therefore, for samples with less strong perpendicular magnetic anisotropy (PMA), a large field fitted damping-like term is more accurate.

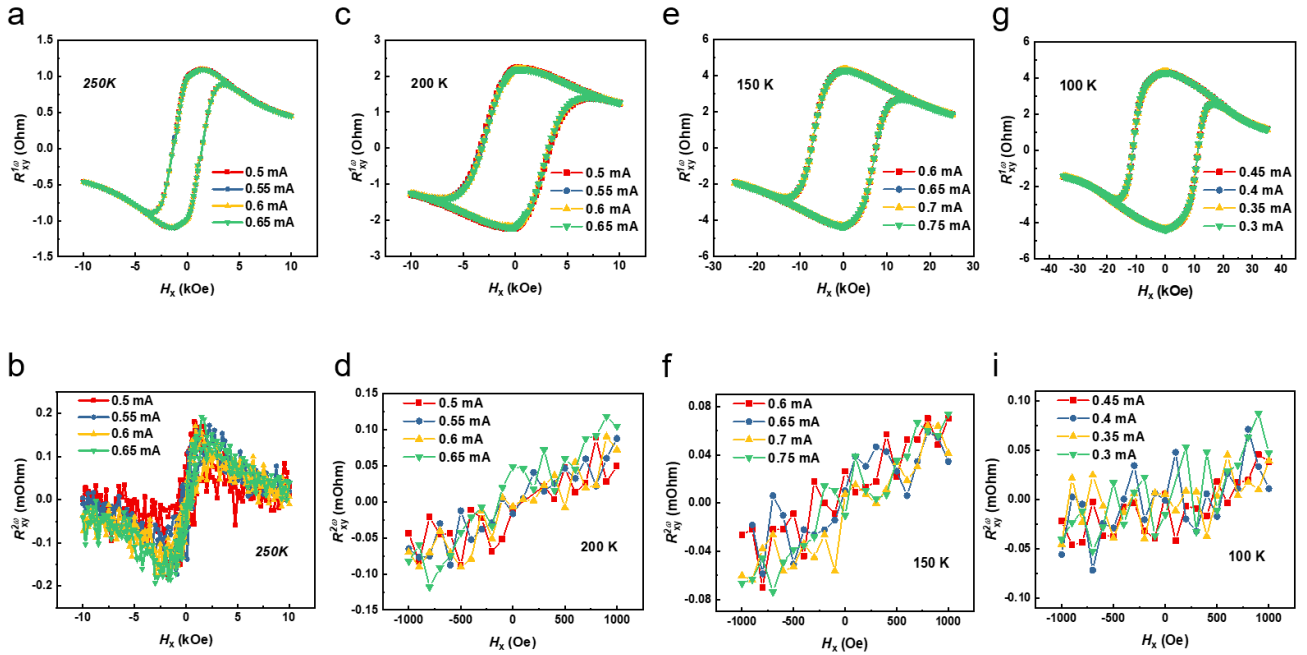
$$\frac{\partial \hat{m}}{\partial t} = -\gamma \hat{m} \times \left( -\frac{\partial E}{\partial \vec{M}} + a_J (\hat{m} \times \hat{p}) + b_J \hat{p} \right) + \alpha \hat{m} \times \frac{\partial \hat{m}}{\partial t} \quad (1)$$

$$R_{2\omega} = \frac{R_A}{2} \frac{H_{DL}}{|H_x| - H_k} + R_p \frac{H_{FL}}{|H_x|} + R_{SSE+ANE} \frac{H_x}{|H_x|} + R_{offset} \quad (2)$$

$$H_{DL(FL)} = -2 \frac{dV_{2\omega}/dH_{x(y)}}{d^2V_{1\omega}/dH_{x(y)}^2} \quad (3)$$

However, in absence of the thermal-related effect, the latter case that followed formula (3) should be more accurate for estimating SOT efficiency, since the former case still included field-like effective term. The formula (3) can make it clear that  $H_x$  and  $H_y$  represent  $a_J$  and  $b_J$ , respectively. The prerequisite condition required by this equation is that the direction of equilibrium magnetization

doesn't deviate significantly from the z-axis<sup>5</sup>. Therefore, we employed the small field derivation fitting method for the Bi<sub>2</sub>Te<sub>3</sub>(8)/FGT(4) heterostructure to evaluate the damping-like SOT efficiency, since this sample shows negligible thermal-related effect and strong PMA feature at low temperature. Compared to formula (3), the presence of field-like term in formula (2) potentially promotes the magnetization switching and affects the damping-like component. Meanwhile, the domain wall reflection at sample edges produces the possible phenomenon of anomalous SOT<sup>9,10</sup>. Following formula (3), we performed the in-phase first and out-of-phase second harmonic Hall measurements on the Bi<sub>2</sub>Te<sub>3</sub>(8)/FGT(4) heterostructure under different alternating currents and temperatures, as shown in Fig. S6. It clearly demonstrates the first and second harmonic signals from 100 K to 250 K, and the fitting results for damping-like SOT efficiency are shown in the main text.



**Figure S6 | Harmonic Hall voltage measurement and SOT efficiency calculation of the Bi<sub>2</sub>Te<sub>3</sub>(8)/FGT(4) heterostructure.** The first harmonic Hall resistance signals (a), (c), (e), (g), and the second harmonic Hall resistance signals (b), (d), (f), (i) along the x-direction for the spin-up (down) states.

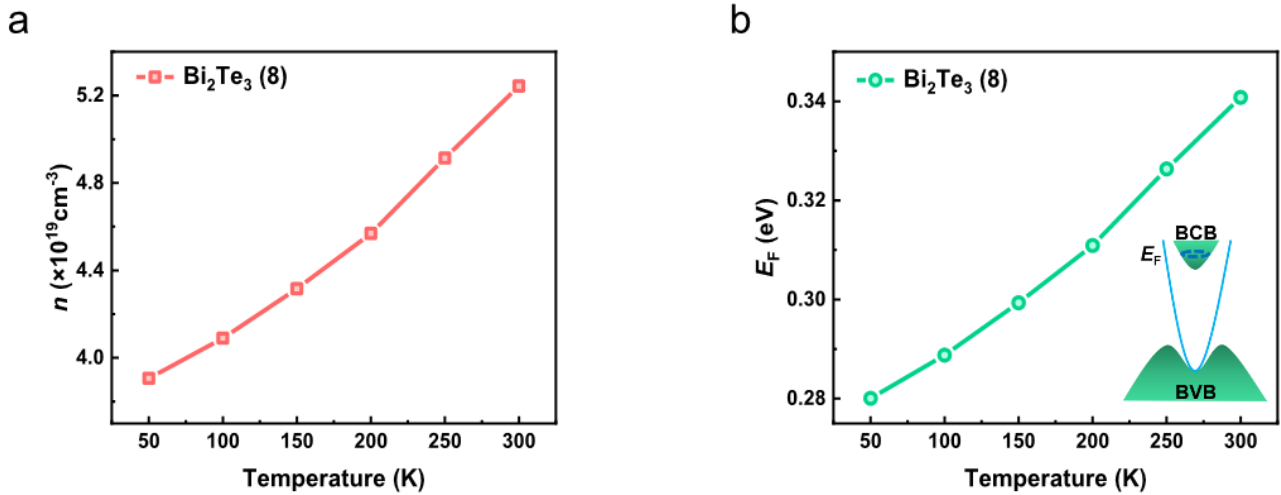


## 7. Estimation of Fermi level in Bi<sub>2</sub>Te<sub>3</sub>(8) structure at different temperature

To quantitatively analyze the position of the  $E_F$  level and its influence on the SOT switching, the following equation was employed<sup>11</sup>:

$$E_F = \hbar^2 / (2m^*) (3\pi^2 n)^{2/3} \quad (3)$$

where  $\hbar$  is the reduced Plank constant,  $m^* \approx 0.15m_0$  is the effective mass and  $n$  is the bulk carrier density. Hence, we further conduct the Hall measurements to estimate the bulk carrier density  $n$  at different temperatures as shown in Fig. S7a. The illustration of the inset elucidates the band structure of Bi<sub>2</sub>Te<sub>3</sub> and the location of the  $E_F$ , which more explicitly reveals the source of Bi<sub>2</sub>Te<sub>3</sub> carriers<sup>12</sup>. The  $E_F$  is located in the bulk conduction band, above the Dirac-cone of surface state<sup>13</sup>. The fact that TI with reduced bulk conductance leads to a higher SOT efficiency suggests that the TSS renders significant contributions to the efficient SOT. Figure. S7b displays the temperature-dependent  $E_F$  values for estimating its position related to the bulk conduction band and the inset presents the simplified diagram.

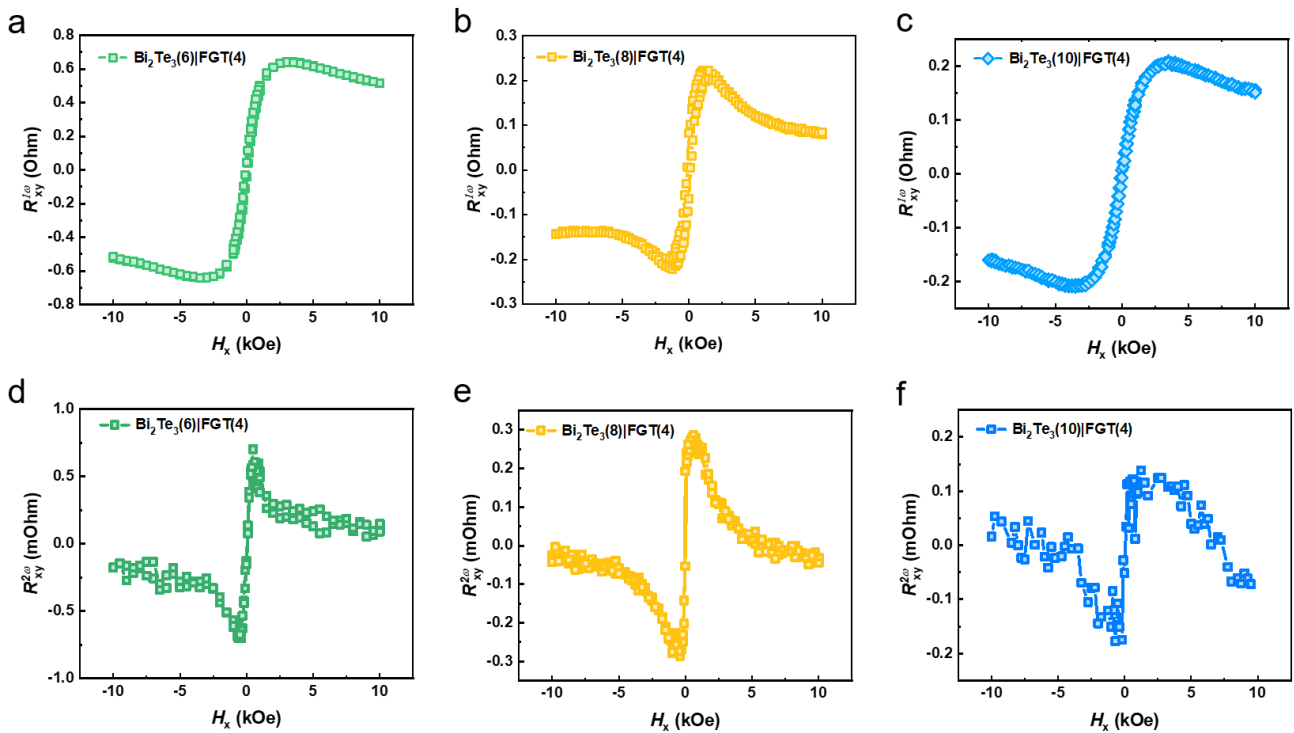


**Figure S7 | Estimation of Fermi level in Bi<sub>2</sub>Te<sub>3</sub>(8) structure at different temperatures.** The bulk carrier density as a function of temperature in Bi<sub>2</sub>Te<sub>3</sub> structure. The inset shows the schematic of the Fermi level position.

## 8. Harmonic Hall voltage measurements in Bi<sub>2</sub>Te<sub>3</sub>(6)/FGT(4) and Bi<sub>2</sub>Te<sub>3</sub>(10)/FGT(4)

## heterostructures at 300K

To comprehensively analyze the physical mechanism of realizing SOT switching, we further prepared the  $\text{Bi}_2\text{Te}_3(6)/\text{FGT}(4)$  and  $\text{Bi}_2\text{Te}_3(10)/\text{FGT}(4)$  heterostructures and carried out the harmonic measurements. Figure S8 displays the in-plane magnetic field-dependent first and second harmonic Hall resistance signals from these two samples, meanwhile the signal from  $\text{Bi}_2\text{Te}_3(8)/\text{FGT}(4)$  was also demonstrated as a reference. The value of the  $H_{DL}/J_{write}$  for  $\text{Bi}_2\text{Te}_3(6)/\text{FGT}(4)$  and  $\text{Bi}_2\text{Te}_3(10)/\text{FGT}(4)$  are  $\sim 69.32$  Oe per  $\text{MA}/\text{cm}^2$  and  $\sim 2.04$  Oe per  $\text{MA}/\text{cm}^2$ , respectively, and the calculated SOT efficiency are correspondingly determined to be  $\sim 2.69$  and  $\sim 0.08$  at 300 K. Hence, the significantly enhanced SOT efficiency through reducing conductive bulk state proves the significant role of surface state. The above results provide insights for distinguishing the surface and bulk contribution that realizes the SOT switching.



**Figure S8 | Harmonic Hall voltage measurements in  $\text{Bi}_2\text{Te}_3(6)/\text{FGT}(4)$  heterostructure at 300K.**

The first harmonic Hall resistance signals (a), (b), (c) and the second harmonic Hall resistance signals

(d), (e), (f) along the x-direction of the external magnetic field with different Bi<sub>2</sub>Te<sub>3</sub> thickness.

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